



**Wide Bandgap Materials Group**

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**SILICON CARBIDE (SiC) SUBSTRATE SPECIFICATION  
 2 INCH (50.8 mm) DIAMETER, 6H POLYTYPE , ON-AXIS ORIENTATION,  
 Prime Grade**

<b>Property</b>	<b>Value</b>	<b>Tolerance</b>	<b>Units</b>
Diameter	50.80	±0.20	mm
Edge Exclusion	2		mm
Center Thickness	400 µm or Customer Specification	±30	µm
Polytype	6H polytype	>95% of area	
Micropipe Density			
n-type	< 100		cm <sup>-2</sup>
Semi-Insulating	< 100		cm <sup>-2</sup>
Face Orientation	c-plane (0001); on-axis	±.5	deg
Front Surface (Si-face): Finish <sup>[1]</sup>	Epiready™ <sup>[1]</sup>		
Scratches by Bright Light	Cumulative Length < 5cm		
Back Surface (C-face): Finish	Customer Specified Fine Ground Standard		
Bow	< 25		µm
Primary Flat Orientation	Perpendicular to (11-20) plane	±1	deg
Secondary Flat Orientation	90° CW from primary flat	±5	deg
Carbon Face Laser Mark Location & Text	Per customer specification		
Edge	Beveled		
Packaging	Single wafer Fluoroware™ container		
Cracks	None		
Cumulative Area Defects	< 10% Area		
Dopant	n-type Nitrogen SI Vanadium Doped		

<sup>[1]</sup> Epiready™ CMP polish is suitable for GaN epitaxial growth